

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Inventors: S. NAKAYAMA, et al.

Application No.: New Patent Application

Filed: March 17, 2004

For: NICKEL-METAL HYDRIDE STORAGE BATTERY AND METHOD
FOR PRODUCING NEGATIVE ELECTRODE THEREOF

INFORMATION DISCLOSURE STATEMENT

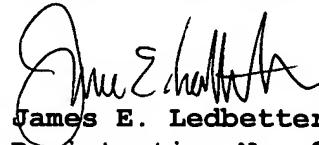
Honorable Commissioner of
Patents and Trademarks
Washington, DC 20231

Sir:

Pursuant to Rules 56 and 99, Applicants hereby call the attention of the Patent Office to the reference(s) listed on the attached Form PTO 1449. JP '908 is discussed in the background section of the application at page 3, line 7, et seq.

Applicants present this art so that the Patent Office may, in the first instance, determine any relevancy thereof to the presently claimed invention, see Beckman Instruments, Inc. v. Chemtronics, Inc., 439 F.2d 1369, 1380, 165 USPQ 355, 364 (5th Cir. 1970). Also see Patent Office Rules 104 and 106. Applicants respectfully request that this art be expressly considered during the prosecution of this application and made of record herein and appear among the "References Cited" on any patent to issue herefrom.

Respectfully submitted,



James E. Ledbetter
Registration No. 28,732

Date: March 17, 2004

JEL/apg
ATTORNEY DOCKET NO. L7016.04103

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FORM PTO-1449 U.S. Department of Commerce (Rev. 4/92) Patent and Trademark Office		ATTY. DOCKET NO.	SERIAL NO.
		L7016.04103	Unassigned
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)		APPLICANT	S. NAKAYAMA, et al.
		FILING DATE	GROUP
		March 17, 2004	Unassigned

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER _____ | **DATE CONSIDERED** _____

EXAMINER: Initial if citation is considered, draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.